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(12) **United States Design Patent**  
**Lang et al.**

(10) **Patent No.:** **US D685,462 S**  
(45) **Date of Patent:** **\*\* Jul. 2, 2013**

(54) **BREATHING MASK**

(75) Inventors: **Bernd Lang**, Gratelting (DE); **Achim Biener**, Munich (DE)

(73) Assignee: **RedMed R&D Germany GmbH**, Martinsried (DE)

(\*\*) Term: **14 Years**

(21) Appl. No.: **29/347,618**

(22) Filed: **Mar. 16, 2010**

**Related U.S. Application Data**

(60) Continuation of application No. 29/311,143, filed on Dec. 31, 2008, now Pat. No. Des. 614,762, which is a continuation of application No. 29/290,110, filed on Oct. 23, 2007, now Pat. No. Des. 585,982, which is a continuation of application No. 29/239,063, filed on Sep. 27, 2005, now Pat. No. Des. 572,816, which is a division of application No. 29/219,617, filed on Dec. 21, 2004, now Pat. No. Des. 515,698, which is a division of application No. 29/190,511, filed on Sep. 23, 2003, now Pat. No. Des. 502,260, which is a division of application No. 29/163,978, filed on Jul. 17, 2002, now Pat. No. Des. 484,237.

(30) **Foreign Application Priority Data**

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(51) **LOC (9) Cl.** ..... **29-02**

(52) **U.S. Cl.**  
USPC ..... **D24/110.1**

(58) **Field of Classification Search**  
USPC ..... D24/110, 110.1, 110.4, 110.5, 110.6;  
128/205.25, 206.13, 206.14, 206.25, 206.28,  
128/206.26, 206.23, 206.18, 207.11, 207.13  
See application file for complete search history.

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*Primary Examiner* — Rashida Johnson

(74) *Attorney, Agent, or Firm* — Nixon & Vanderhye P.C.

(57) **CLAIM**

The ornamental design for a breathing mask, as shown and described.

**DESCRIPTION**

FIG. 1 is a perspective view of a breathing mask according to our design;

FIG. 2 is a front view thereof;

FIG. 3 is a rear view thereof;

FIG. 4 is a right side view thereof;

FIG. 5 is a left side view thereof;

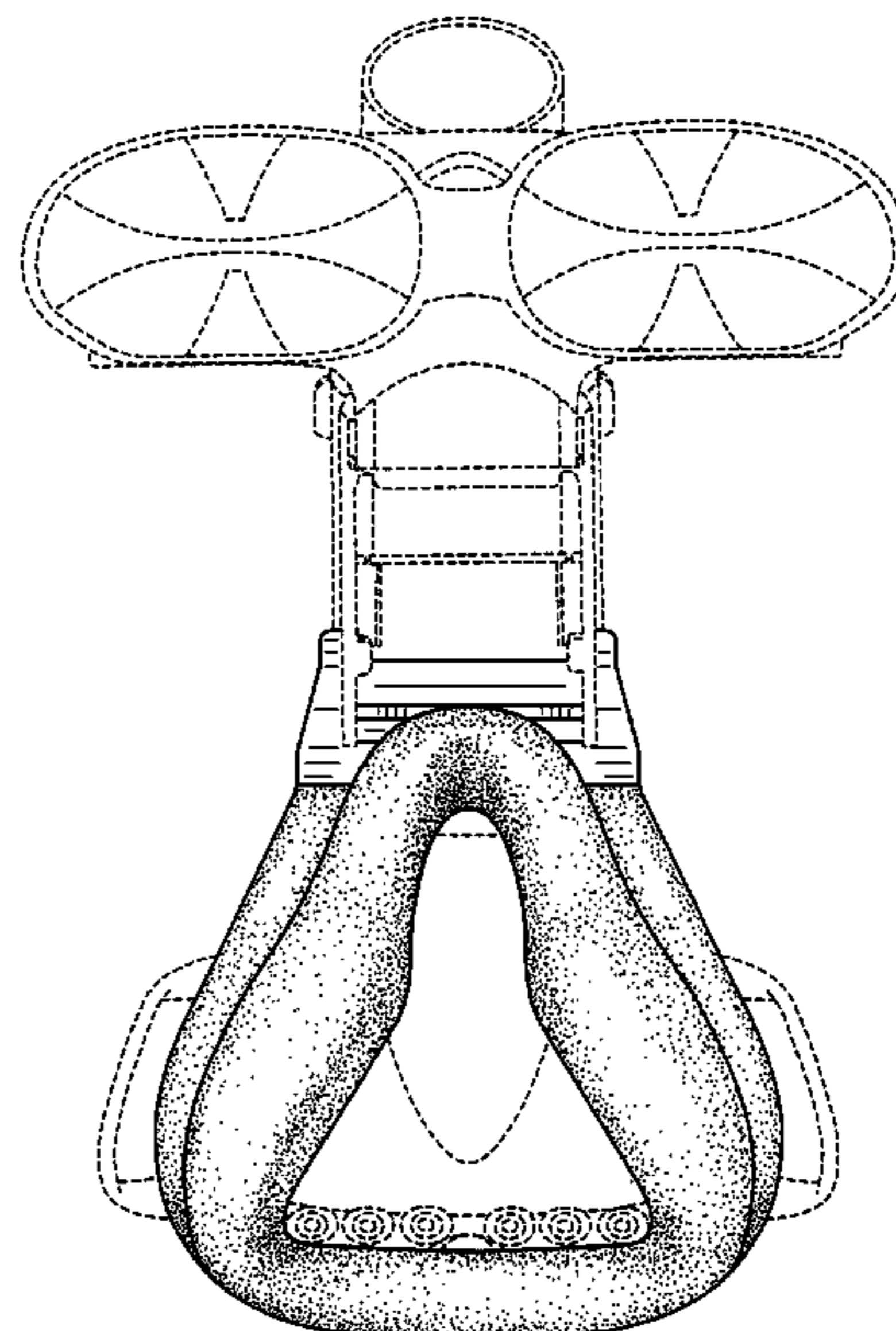
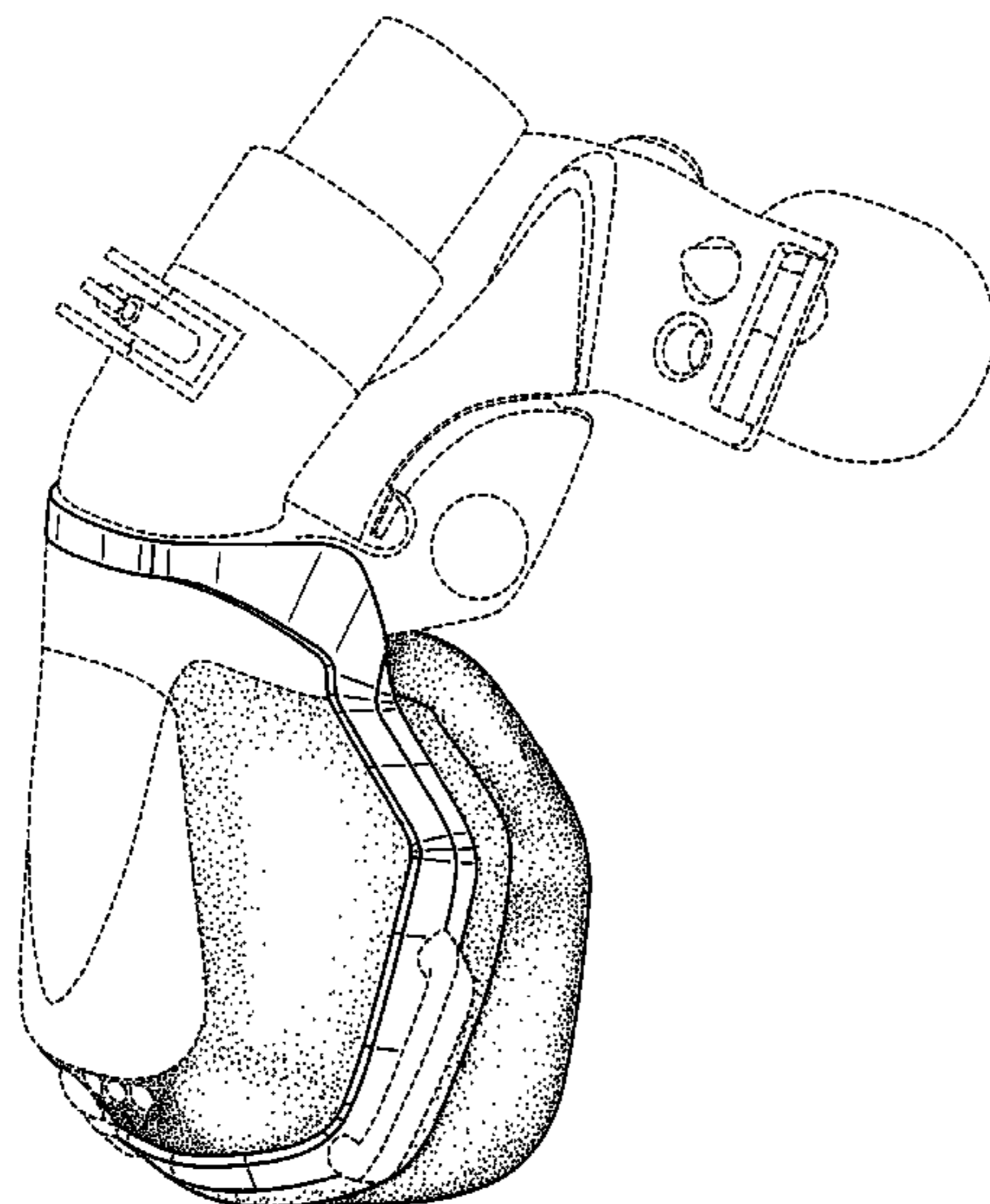
FIG. 6 is a top view thereof; and,

FIG. 7 is a bottom view thereof.

The broken lines showing environment or structure of the breathing mask are for illustrative purposes only and form no part of the claimed design.

The stippling represents a contrast in material.

**1 Claim, 7 Drawing Sheets**



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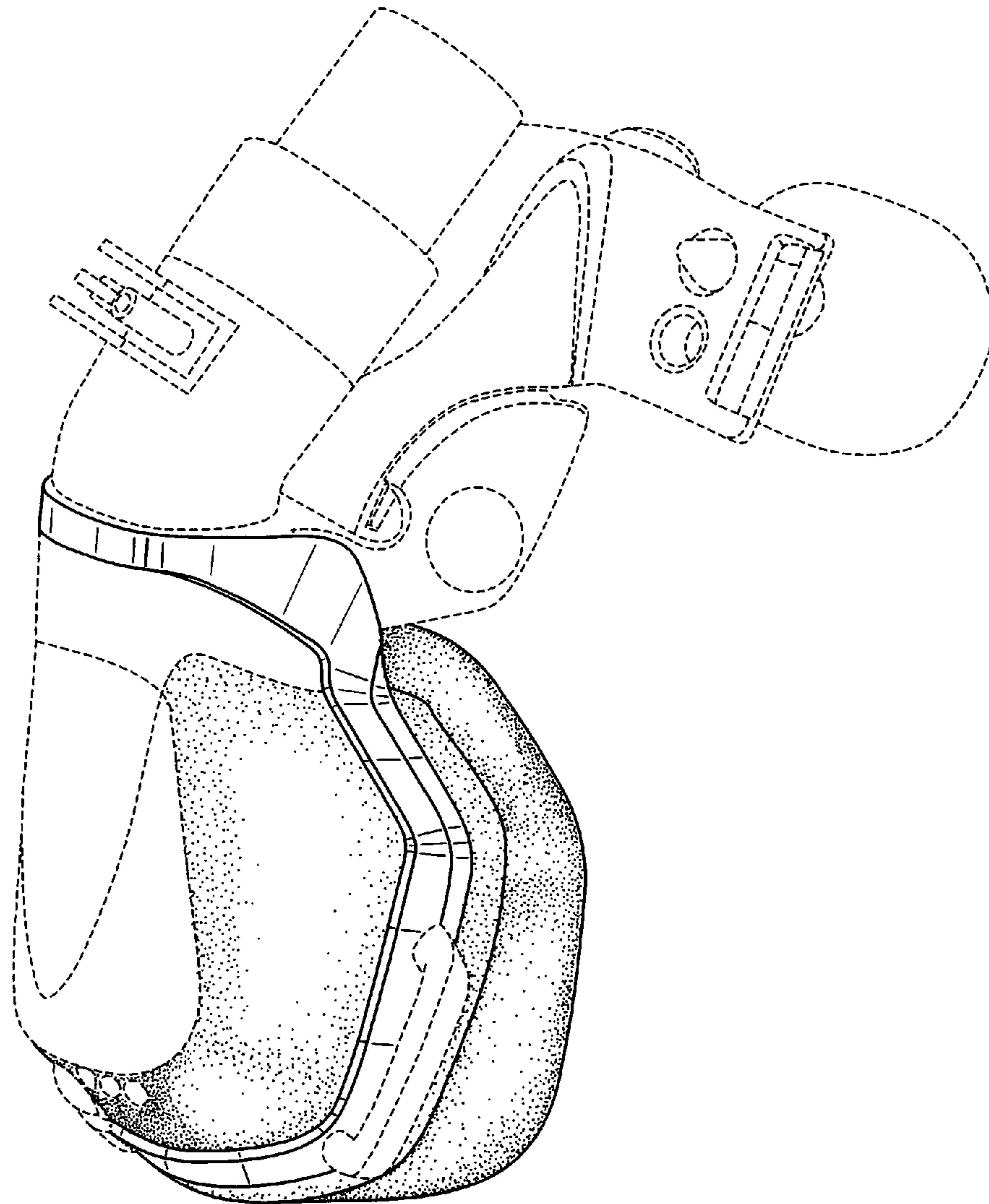
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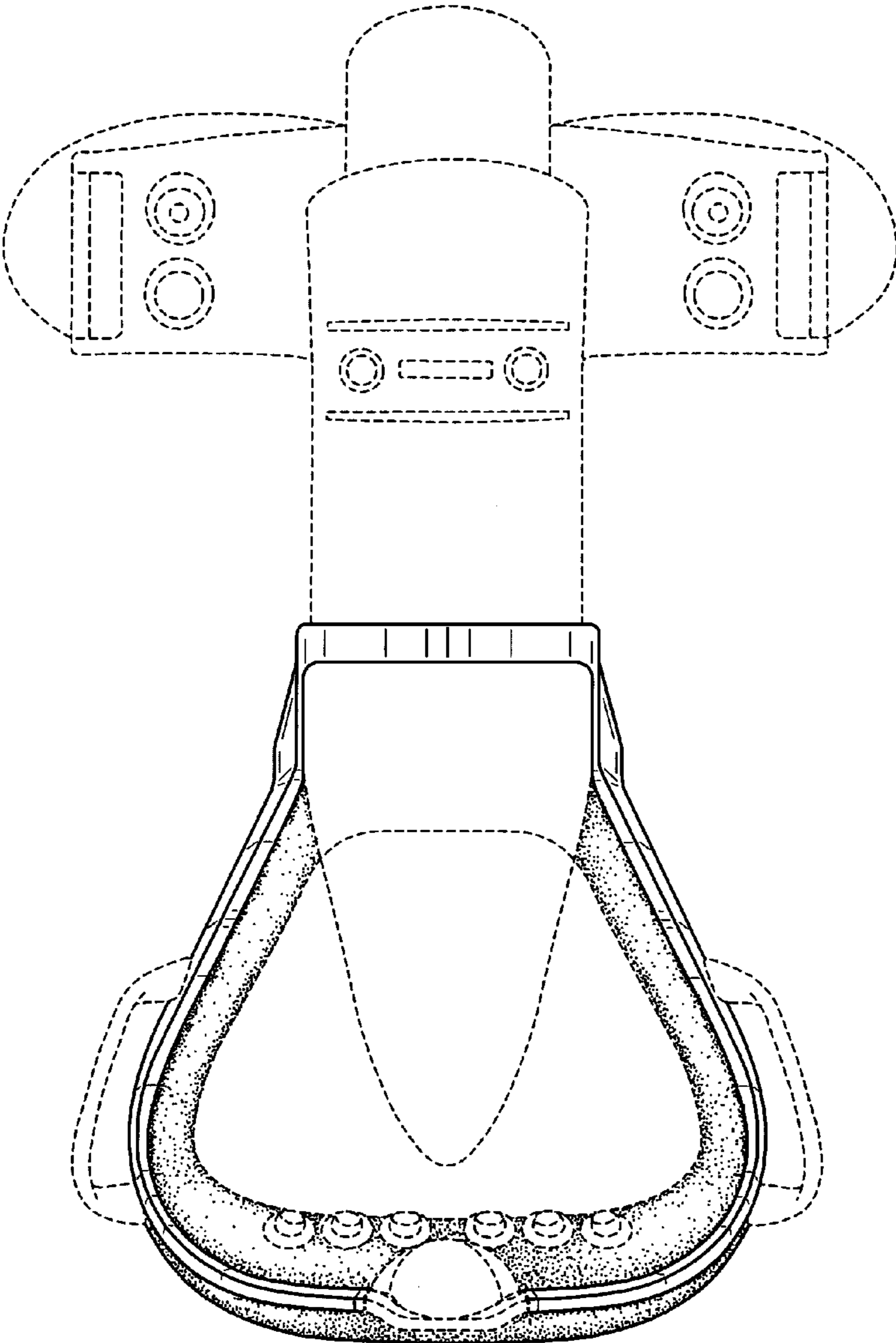
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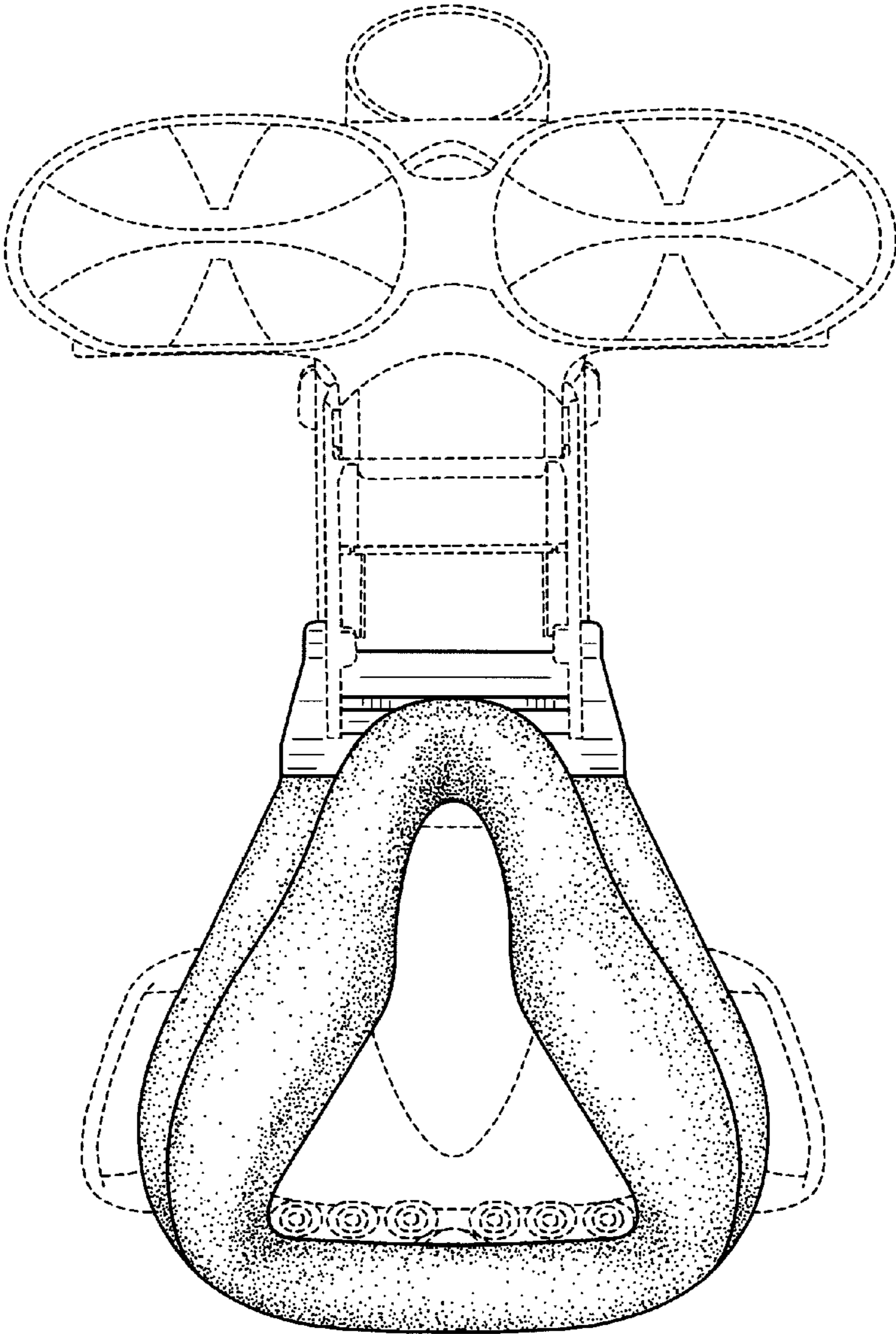
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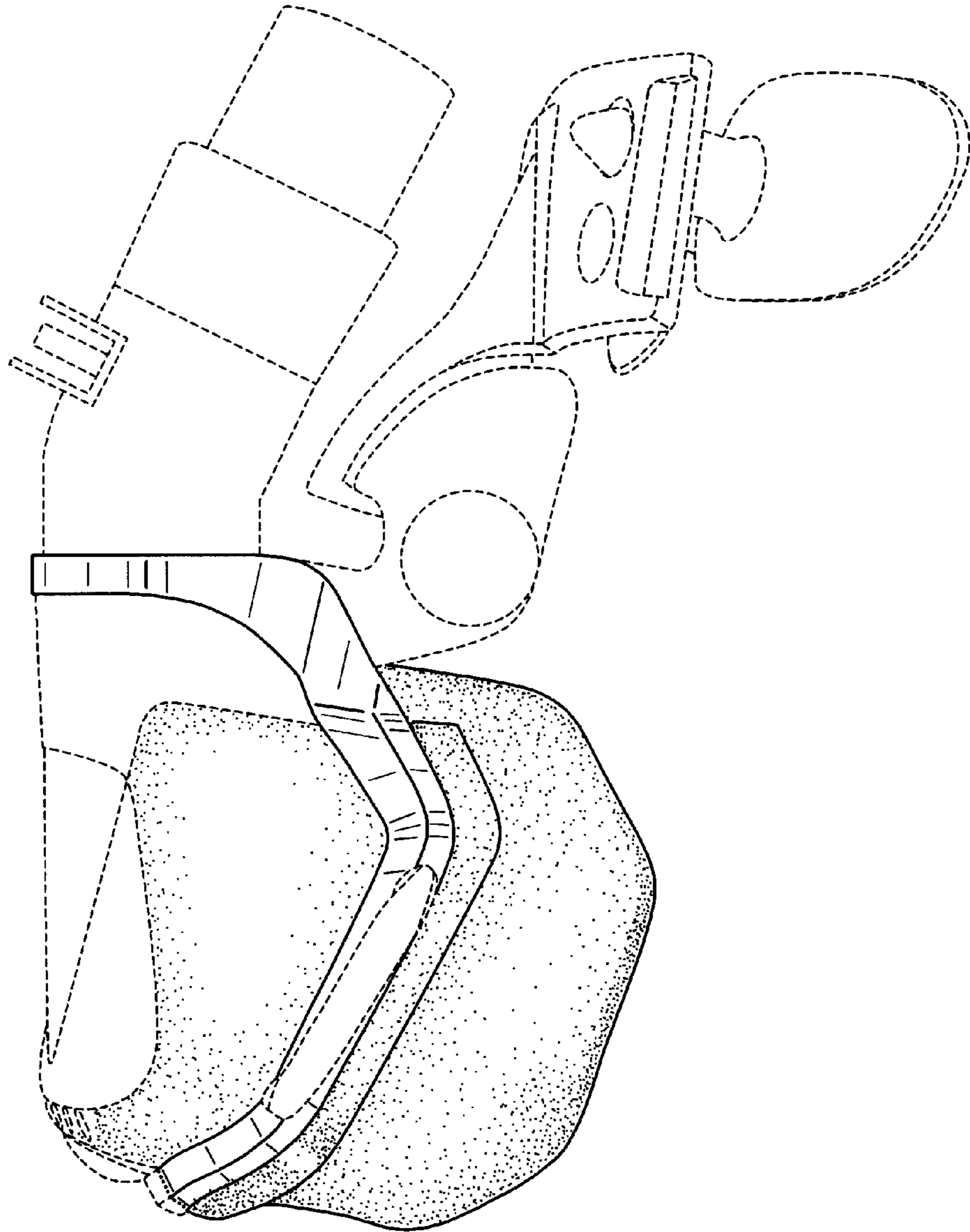
**FIG. 1**



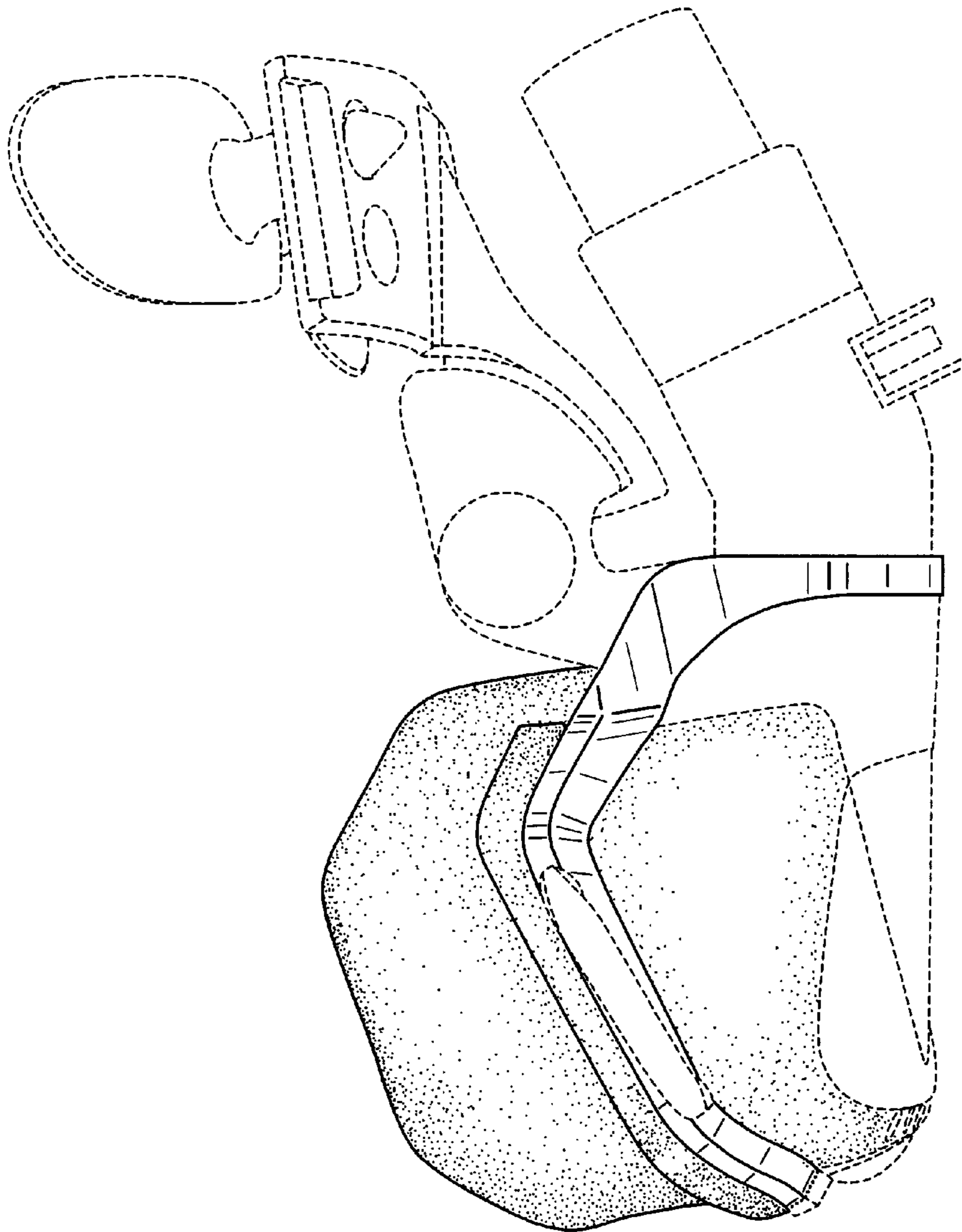
**FIG. 2**



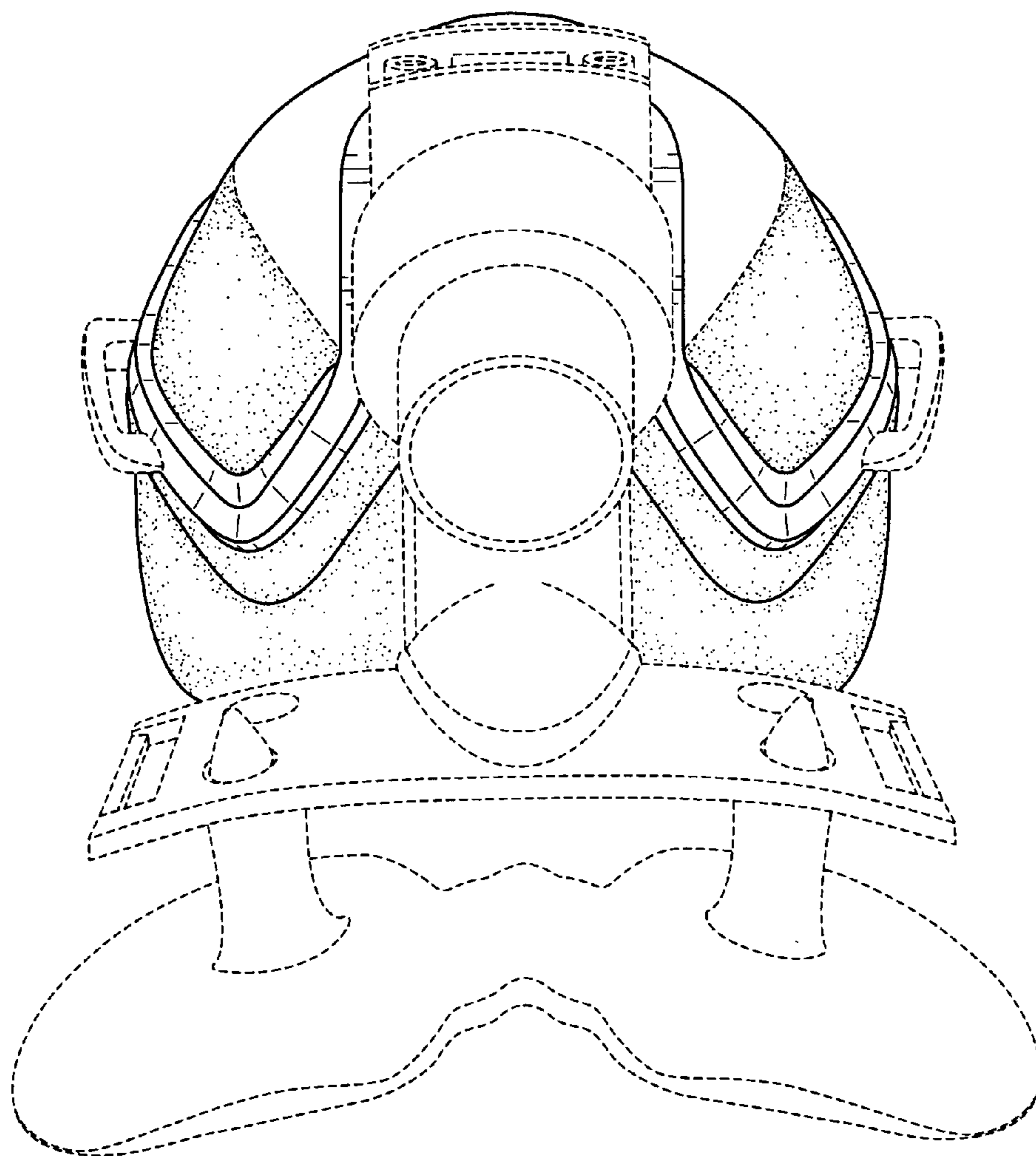
**FIG. 3**



**FIG. 4**

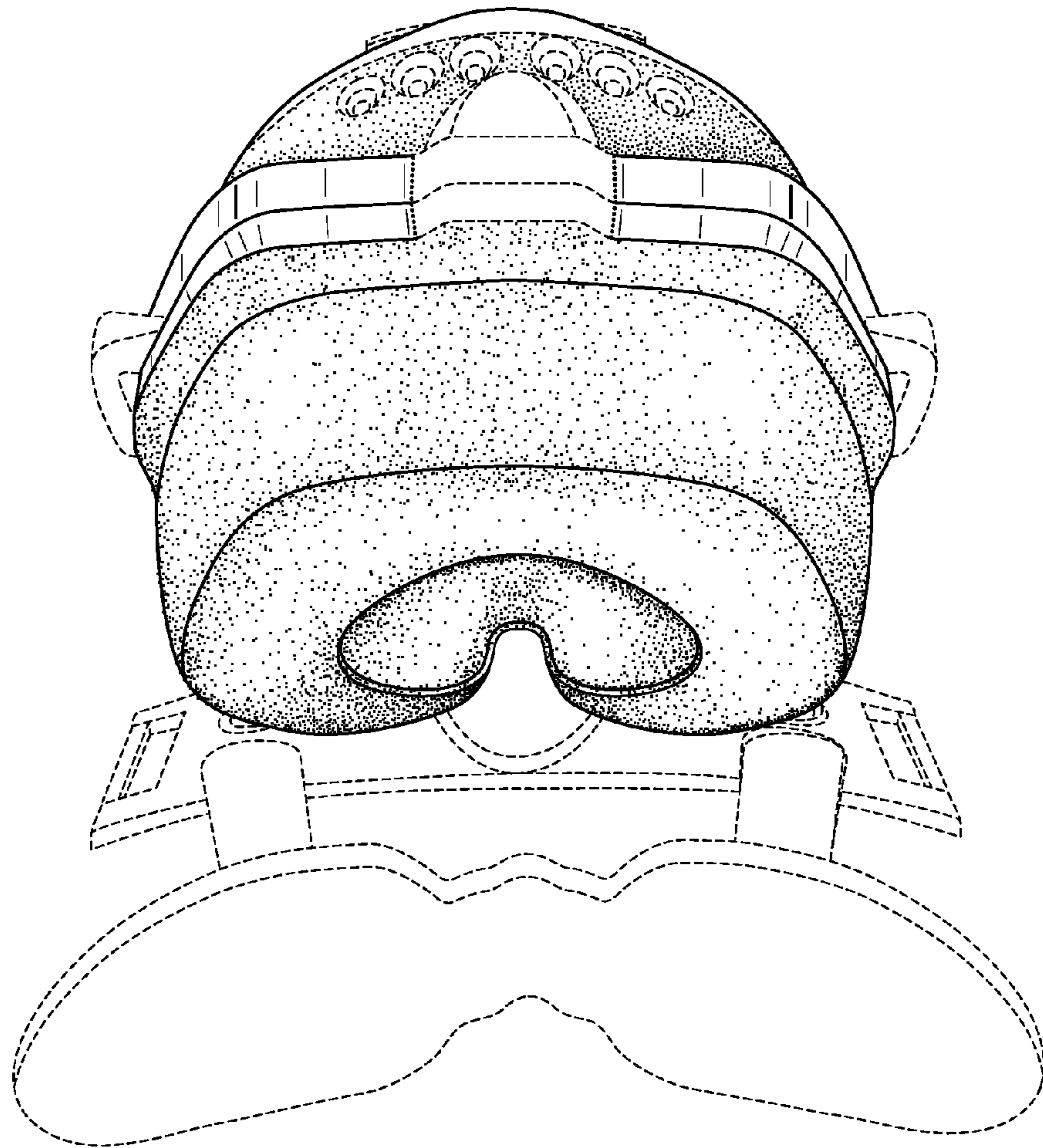


**FIG. 5**



**FIG. 6**





**FIG. 7**